

Our Ref.: 3008-0034
File No.: 521.41463X00
Client Ref.: PHCF-01103

FEB 12 2003

PATENT

11/1/03
3/21/03

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Oka et al

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:
: Art Unit: 2811

Application S/N 09/925,626

:
: Examiner: Shouxiang Hu

Filed: August 10, 2001

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For: CRYSTALLINE SILICON THIN FILM SEMICONDUCTOR DEVICE,
CRYSTALLINE SILICON FILM PHOTOVOLTAIC DEVICE, AND PROCESS FOR
PRODUCING CRYSTALLINE SILICON THIN FILM SEMICONDUCTOR DEVICE

AMENDMENT UNDER 37 CFR §1.111

Honorable Assistant Commissioner
for Patents
Washington, DC 20231

Sir:

In response to the Official Action dated August 14, 2002, the time for response to which is extended three (3) months, up to and including February 14, 2003, please amend the above referenced application as follows.

IN THE CLAIMS

Please amend the claims as follows:

✓ Please cancel claims 14-16.

✓ Please amend claims 1, 11 and 13 to read as follows:

13 *Sub 7* *CI 7* (Amended) A crystalline silicon thin film semiconductor device comprising:

a conductive substrate or a substrate having on its surface a conductive layer;

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